

Artist: NOTE NEW FIG 1 1/14

Artist: shades as)

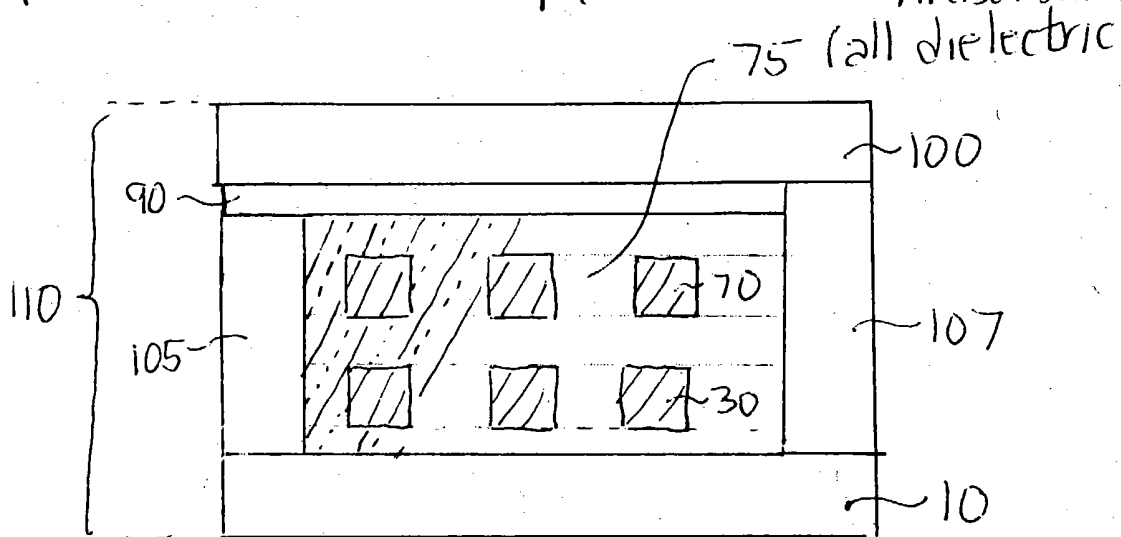


Fig 1

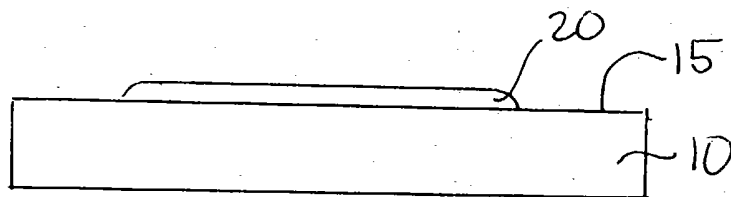


Fig 2

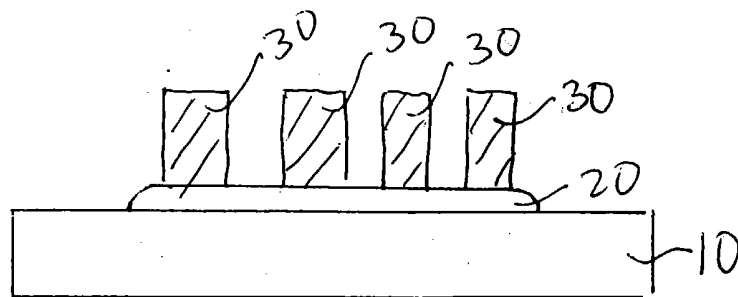
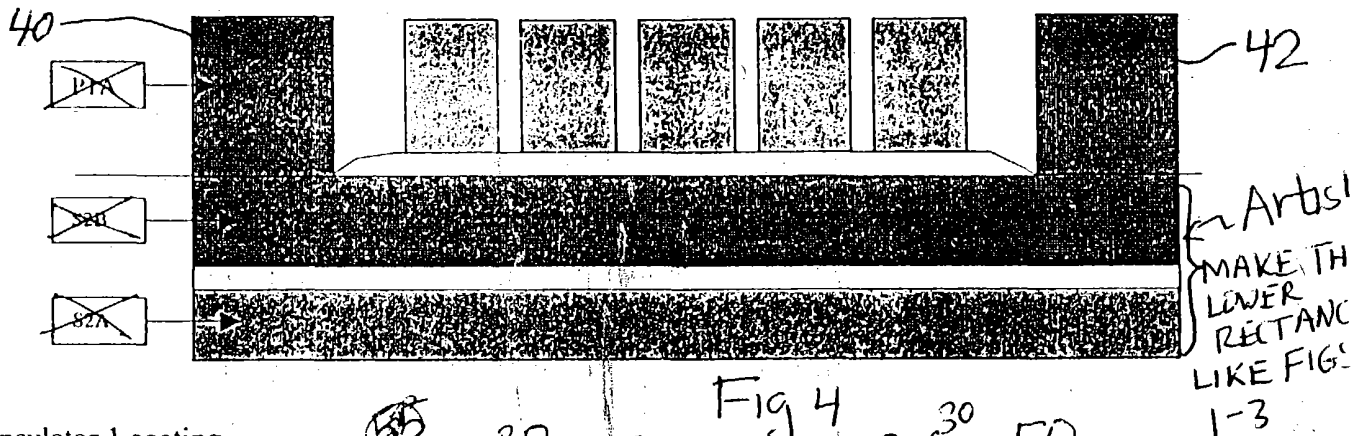
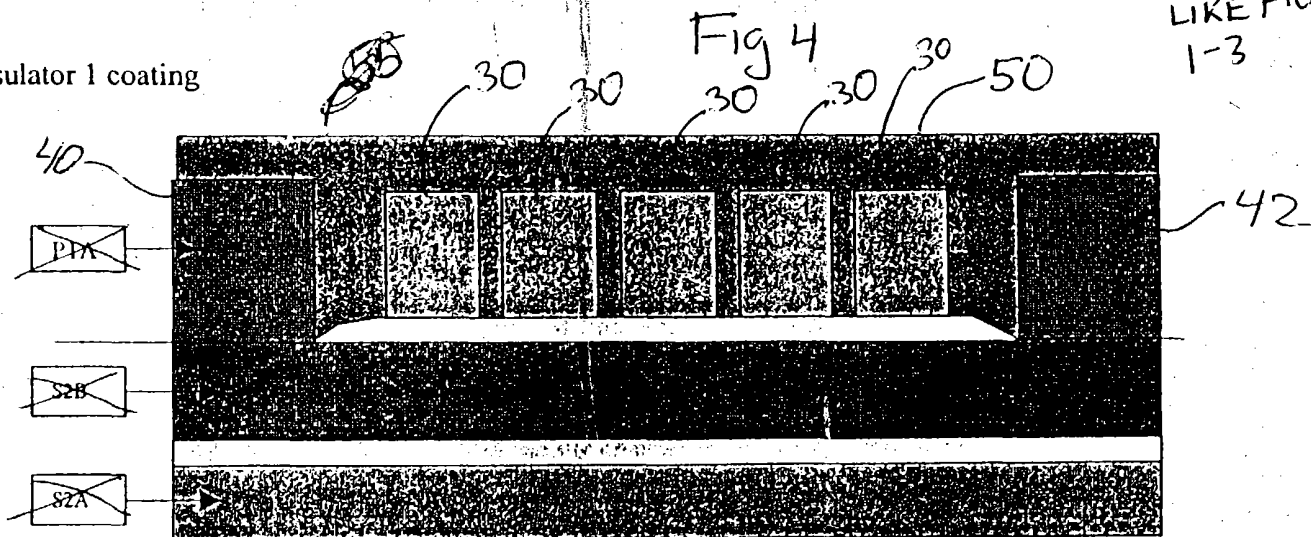


Fig 3

4. P1A seed layer deposition and pattern formation



5. Insulator 1 coating



6. P1A DP and CMP process

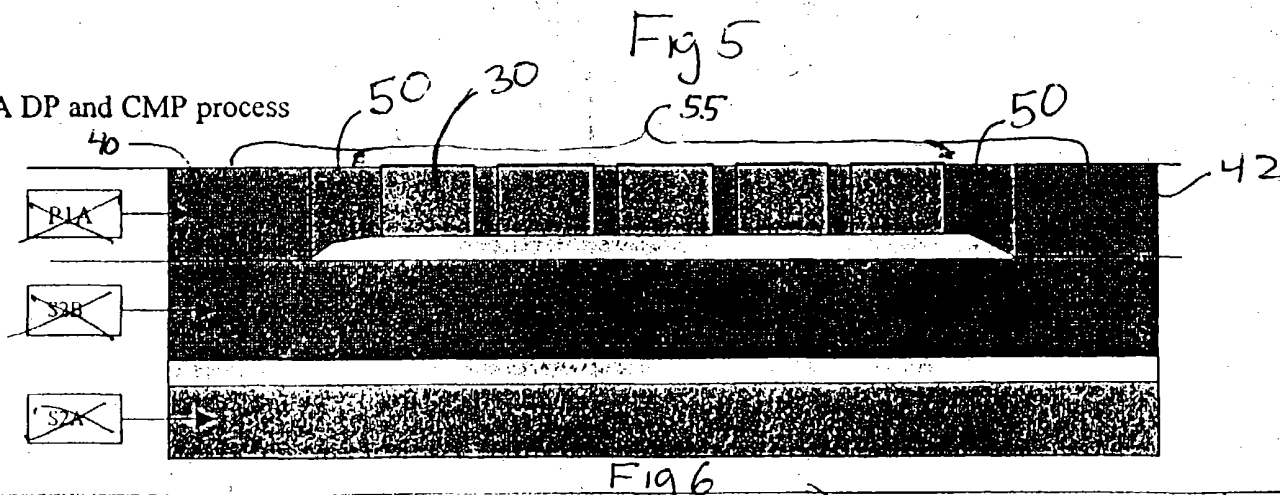


Fig 6

7. Second alumina patch (2000A) and via etch by IBE process

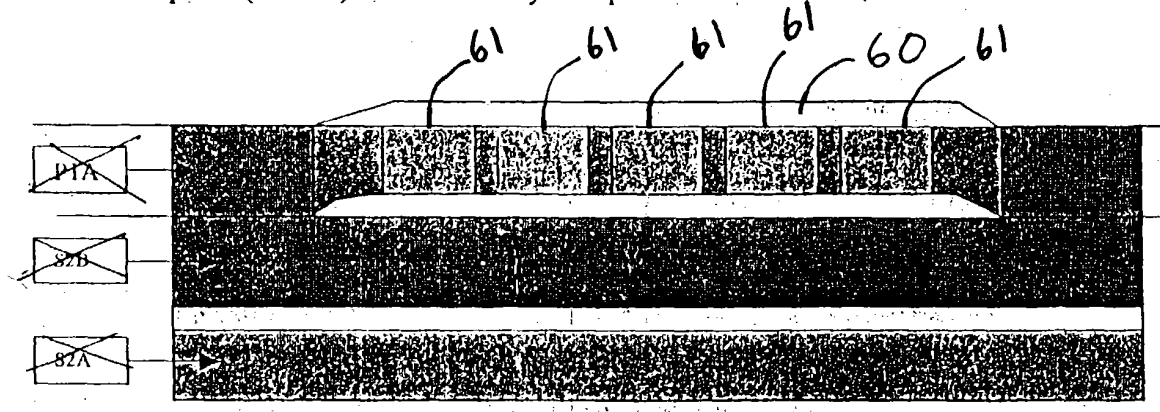


Fig 7

8. Second coil layer formation

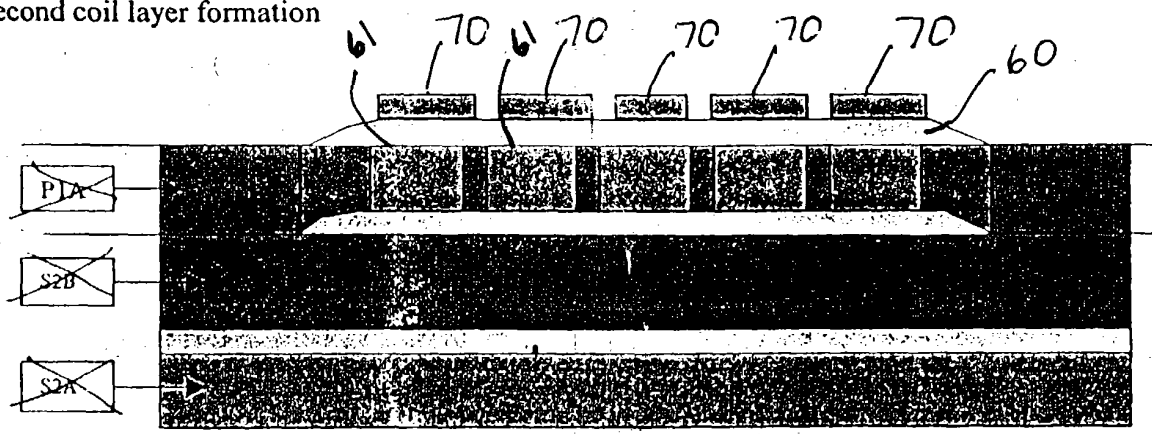


Fig 8

9. P1B seed layer deposition and pattern formation

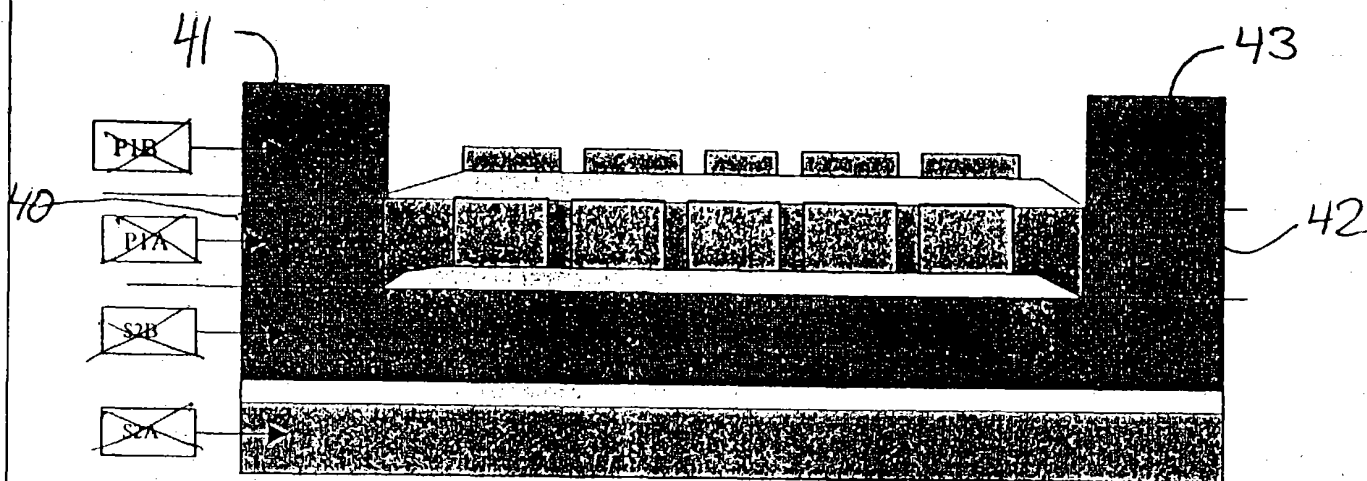


Fig. 9

10. Insulator 2 patterning

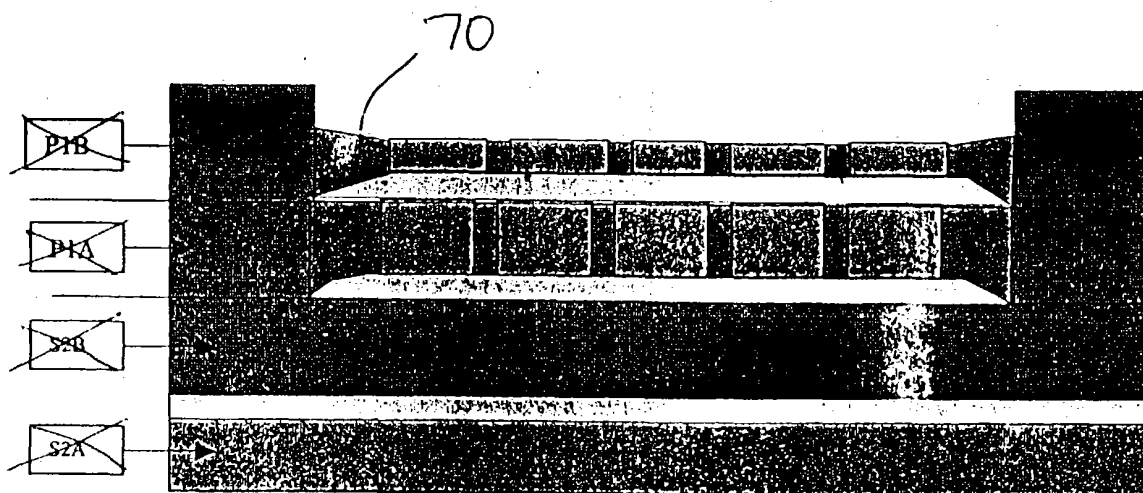


Fig. 10

11. P1B DP and CMP

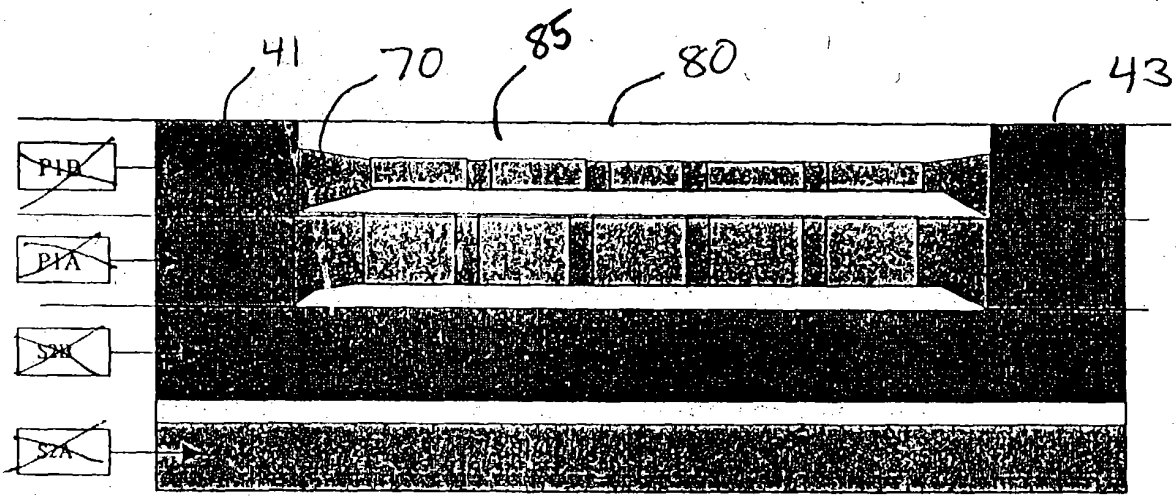


Fig 11

12. P2 high moment seed deposition and P1S formation

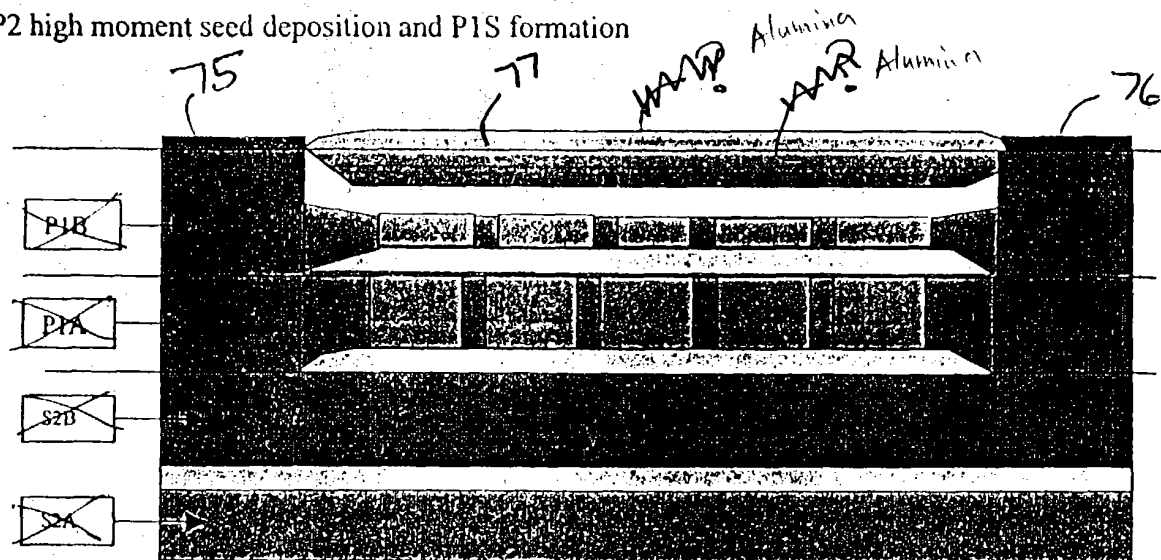
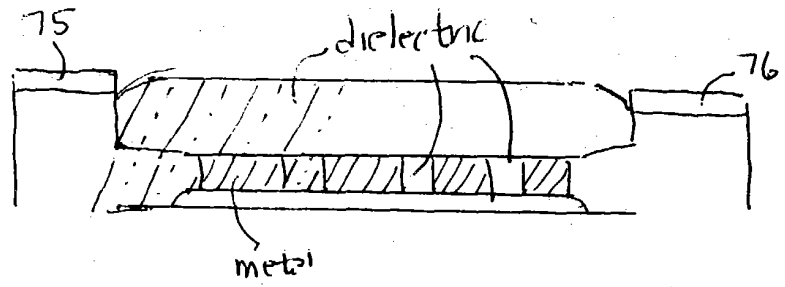


Fig 12

Artist: Upper portion of Fig 12

should look like:→
(words are for
the artist!)



13. WG formation

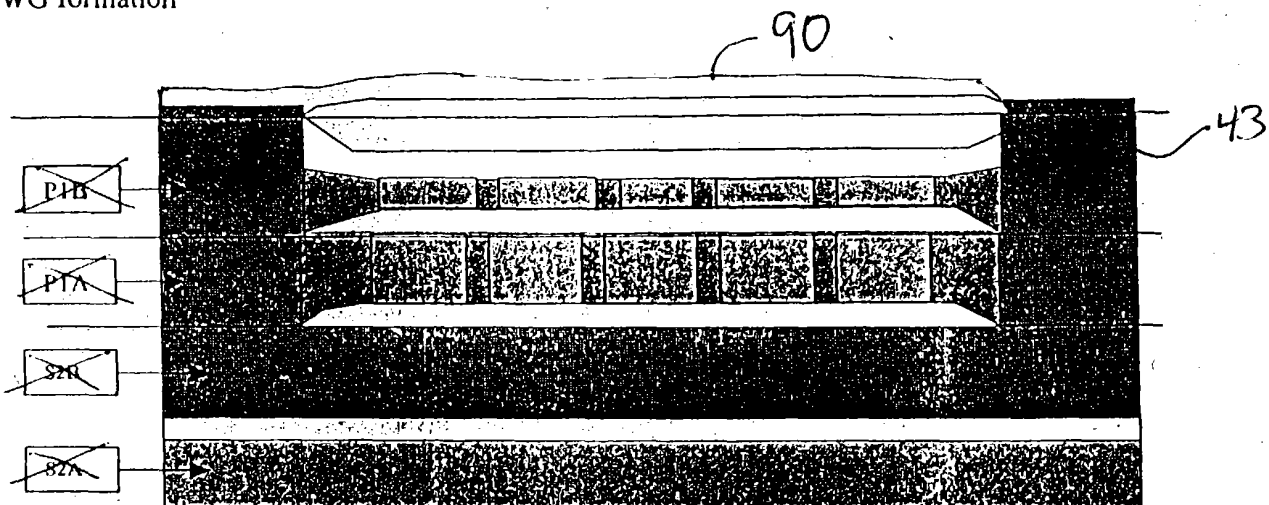


Fig 13

14. P2 seed layer deposition and P2 formation

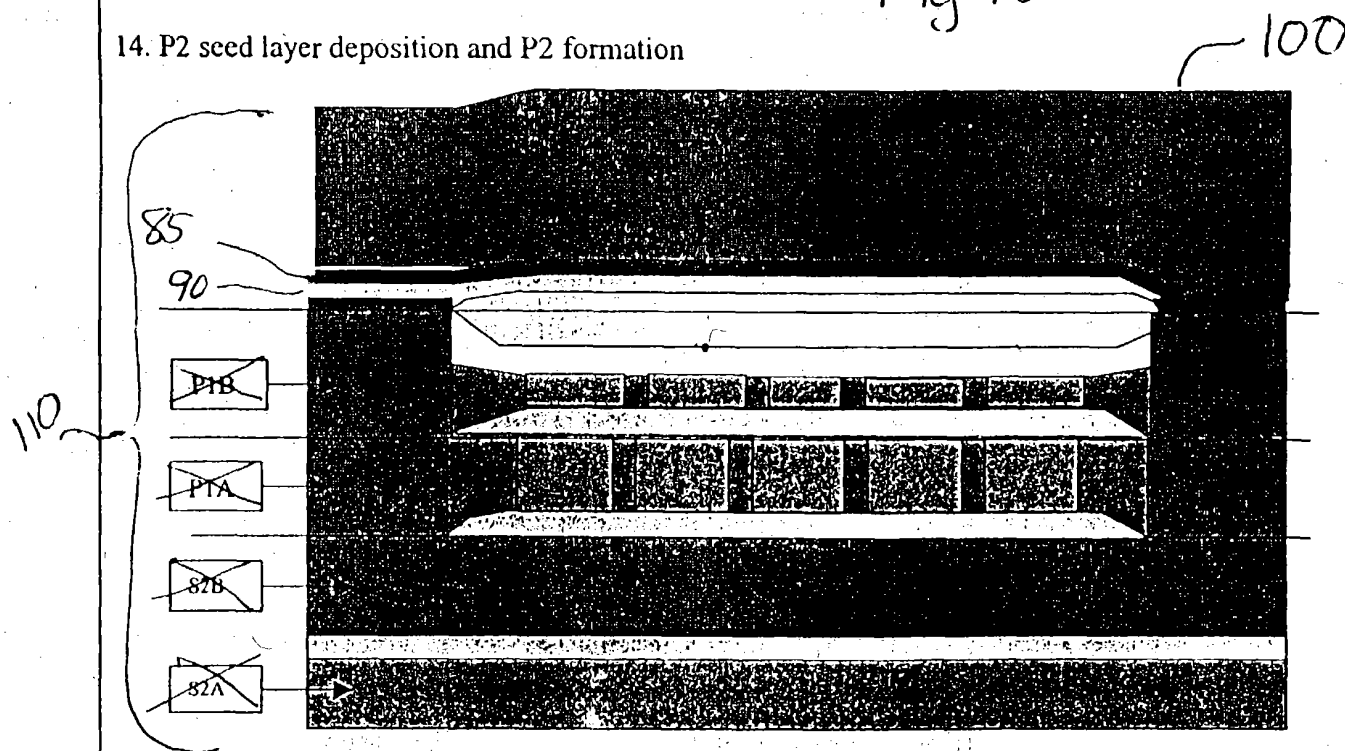


Fig 14